

# On Laminar Flow in Microfabricated Channels with Partial Semi-Circular Profiles

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## **ABSTRACT**

Soft and hard micromachining techniques used to develop microfluidic devices can yield microchannels of many different cross-sectional profiles. For semi-circular microchannels, these techniques often produce only *partial* semicircular (PSC) cross-sections. This study investigated fully developed laminar flow in PSC microchannels as a function of a circularity index,  $\kappa$ , defined as the ratio of the radiuses along the curved and flat surfaces of the PSC profile. A correction factor, K, to the Hagen-Poiseuille relation was determined and was well-fitted by the power-law relationship  $K = 5.299/\kappa^{2.56}$ . Actual correction factors were compared to estimates based on several hydraulic models for flow in microchannels of arbitrary cross-section, as well as the half-ellipsoid cross-section. The level of wall shear stress, when normalized by the pressure drop per unit length, increased approximately linearly with increase in the circularity index,  $\kappa$ .

Keywords: Hagen-Poiseuille Flow; Poiseuille Flow; Flow Resistance; Wall Shear Stress

#### 1. Introduction

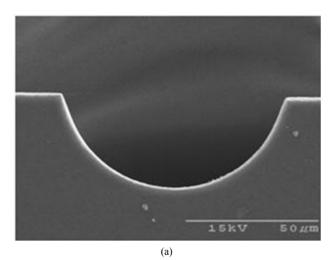
The trend toward miniaturization that has been driven by advances in fabrication processes derived from microelectromechanical systems (MEMs) and other microsystem technologies has led to microfluidic devices for use in numerous chemical, biological and medical applications. Microfluidics refers to devices for accommodating and controlling flow through microchannels with cross-sectional scales of 10 - 100 microns. For many traditional applications, microchannels are fabricated on silicon or quartz substrates using photolithographic methods derived directly from MEMs processes. Whitesides and coworkers extended these "hard" microfabrication techniques into the novel realm of soft lithography to create microchannels and other microfluidic devices in elastomeric materials such as polydimethylsiloxane (PDMS), principally with advantages in biological and biomedical applications [1]. The processes underlying hard and soft microfabrication allow for different microchannel shapes tailored to specific applications. While rectangular microchannels are ubiquitous, the second most common microchannel geometry may be the semi-circular profile, which occurs naturally in hard micromachining with isotropic etching in the photolithographic steps [2]. In soft lithography, plasma etching can also be tailored to provide rounded corners to silicon negative masters, that then yield elastomeric microchannels with semi-circular profiles after spin coating [3,4]. The rounded edges of semicircular profiles help promote cell seeding and proliferation in microfluidic devices developed for tissue engineering [3].

Recent studies that have developed microchannels with semi-circular profiles include an analysis of shear stress effects on endothelial cells in curved microvessels [5], the evaluation of micromachined flow cytometers with integrated optics [6,7], the creation of a novel magnetohydrodynamic micropump [8], and studies of microfluidic devices for capillary electrophoresis [9]. Our own group recently developed biohybrid artificial lung modules with semi-circular endothelialized blood microchannels subjacent to rectangular gas microchannels [10].

The semi-circular microchannels that are fabricated using hard or soft micromachining can best be characterized as partial semi-circular (PSC) microchannels, in which the "radius" to the curved-side is appreciably less than the "radius" along the flat-side. **Figure 1(a)** displays an SEM image of the typical PSC cross-section obtained using soft-lithography from our work on biohybrid artificial lung modules [10], while **Figure 1(b)** shows an SEM image of a PSC microchannel developed using hard-micromachining for a microfluidic capillary electrophoresis device [9]. A circularity index,  $\kappa$ , can be defined as the ratio of the radius to the curved-side relative to that

along the flat-side, with  $\kappa = 1$  representing a complete semi-circular profile. The values of  $\kappa$  are approximately 0.84 and 0.80 for the PSC microchannels shown in **Figures 1(a)** and **(b)**, respectively.

In this study, we analyze fully-developed flow in partial semi-circular (PSC) microchannels using an analytic-cal solution ( $\kappa=1$ ) and numerical simulations ( $0.5 \le \kappa < 1.0$ ) using Comsol Multiphysics. The analysis and results presented focus primarily on determining a correction factor to the Hagen-Poiseuille pressure drop-flowrate relationship for fully-developed flow in circular channels and on characterizing the maximum and average wall shear stress. While the equation of motion for fully-developed flow in a complete semi-circular microchannel ( $\kappa=1$ ) can be analytically solved, the analytical solution was not found in our literature search and our solution is presented in the Appendix. Several recent



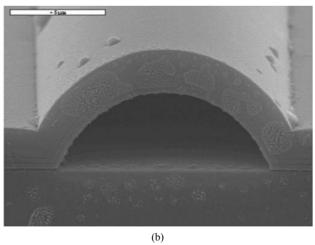


Figure 1. (a) Example 1 of the partial semi-circular (PSC) cross-sectional profiles for microchannels fabricated using soft techniques. Adapted from (Burgess *et al.* 2009); (b) Example 2 of the partial semi-circular (PSC) cross-sectional profiles for microchannels fabricated using hard micromaching techniques. Adapted from (Peeni *et al.* 2005).

studies have addressed fully-developed flow in microchannels of arbitrary and/or specific cross-sectional shapes. Oosterbroek [11] used analytical and approximation techniques to determine or estimate the velocity profiles in different microchannel geometries. The geometry which models closest the PSC microchannel was the half-ellipsoid. Variational principles based on minimizetion of work were adapted from analogous structural mechanics problems related to beam torsion to estimate the velocity profile and flow resistance for the half-ellipsoid microchannel. For microchannels of arbitrary cross-section, Mortensen et al. [12] showed that the hydraulic resistance can be approximated as a linear function of a compactness factor, which is defined as the ratio of the perimeter squared to the cross-sectional area of the microchannel. The linear relationship was determined from the analytical velocity profiles for flow in microchannels of full-ellipsoid, rectangular, and triangular shape. Bahrami et al. [13] developed a novel approximate solution for estimating the flow resistance of microchannels of any arbitrary cross-section based solely on a single geometrical feature, the dimensionless polar moment of inertia of the cross-section. The approximate solution compared well with analytical and numerical results for flow in microchannels of several different geometries. The results of our study on fully-developed flow in PSC microchannels are compared and evaluated against the theories described above in these recent studies.

#### 2. Theoretical Model and Simulations

The geometry and geometrical parameters for the partial semi-circular (PSC) microchannel are shown in **Figure 2(a)** in the x, y plane, where z is the direction of flow. The flat, bottom-side of the PSC is of length, D, and the height of the PSC is given as  $\kappa D/2$ , so that  $\kappa = 1$  represents a complete semi-circular channel. This study considers the flow resistance of PSC microchannels in the range of  $\kappa$  from 0.5 to 1.0.

Fully developed laminar flow in the z direction for a Newtonian fluid is governed by

$$\nabla^2 V = -\frac{1}{\mu} \frac{\Delta P}{L} \tag{1}$$

where V = V(x, y) is the magnitude of the velocity in the z direction,  $\nabla^2$  is the Laplacian operator in x, y space,  $\mu$  is the fluid viscosity, and  $\Delta P/L$  is the pressure drop per unit length in the direction of flow. The flow is also governed by the no-slip condition on the wall (w) surfaces of the microchannel:

$$V = 0 \text{ for } \mathbf{R} \in S_{w} \tag{2}$$

The governing equation can be solved numerically most conveniently by introducing dimensionless dependent and independent variables. The spatial coordi-

nates (x, y) are scaled by the flat surface width, D, while the flow velocity is scaled according to:

$$U \equiv V / \frac{D^2}{\mu} \frac{\Delta P}{L} \tag{3}$$

The resulting dimensionless equation of motion is given by:

$$\nabla^{*2}U = -1 \tag{4}$$

where  $\nabla^{*2}$  is the dimensionless Laplacian operator on the domain shown in **Figure 2(b)**.

The no-slip boundary condition requires U = 0 on the surfaces in **Figure 2(b)**.

Comsol Multiphysics® Version 3.4 was used to numerically solve Equation (4), subject to its boundary condition, on the dimensionless domain (**Figure 2(b)**) using the Poisson equation solver in the basic multiphysics module of Comsol. The solution for the dimensionless flow velocity was integrated over the dimensionless domain (subdomain integration in Comsol) to obtain a "correction factor" to the Hagen-Poiseuille relation for laminar flow in a circular conduit. The correction factor, K, is defined from the integrated dimensionless velocity for convenience as

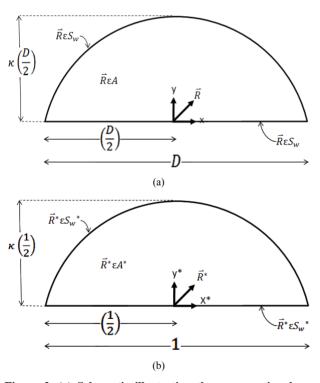


Figure 2. (a) Schematic illustrating the cross-sectional geometry of the PSC microchannel in dimensional forms. The circularity index denotes the departure from a full semicircular channel ( $\kappa=1$ ); (b) Schematic illustrating the cross-sectional geometry of the PSC microchannel in dimensionless forms. The circularity index denotes the departure from a full semi-circular channel ( $\kappa=1$ ).

$$\int_{A^*} U \mathrm{d}A^* = \frac{\pi}{128} K^{-1} \tag{5}$$

where  $dA^*$  and  $A^*$  indicate integration over the dimensionless domain (**Figure 2(b)**). With this definition, transforming Equation (5) back into dimensional form yields:

$$\Delta P = K \frac{128\mu L}{\pi D^4} Q \tag{6}$$

where Q is the volumetric flowrate through the channel. Thus, the correction factor K represents the proportion by which the flow resistance ( $\Delta P/Q$ ) is increased in a PSC microchannel compared to a circular duct of diameter, D.

Also of interest is the shear stress exerted on the wall by the flowing fluid. The wall shear stress is the z component of the fluid stress vector exerted on the wall:  $\tau = n * \tau$ , where  $\tau$  is the stress tensor, given for a Newtonian fluid by  $\tau = \mu \Big[ \nabla V + (\nabla V)^t \Big]$ , and  $\tau n$  is a unit normal vector at the wall directed into the domain. Applying these relationships and noting that V = Vk, the wall shear stress in the PSC microchannel is given by

$$\tau_{w} = \mu \mathbf{n} * \nabla V \tag{7}$$

which can be determined in a normalized form directly from the numerical solution by computing the normal derivative of the dimensionless velocity at the wall:

$$\frac{\tau_{w}}{D(\Delta P/L)} = \boldsymbol{n} * \nabla^{*} U \tag{8}$$

## 3. Results and Discussion

#### 3.1. Hagen-Poiseuille Correction Factor

Fully developed laminar flow in partial semi-circular (PSC) microchannels was numerically simulated using Comsol Multiphysics®. The "partial" nature of the PSC microchannel was specified by the dimensionless parameter,  $\kappa$  wherein the height of the PSC microchannel was  $\kappa D/2$ , with D being the diameter or width of the flat-side of the PSC microchannel. Laminar flow was characterized over the range  $0.5 \le \kappa \le 1.0$ . Simulations were performed using dimensionless variables with the

velocity (V) normalized according to 
$$V / \left(\frac{D^2}{\mu} \frac{\Delta P}{L}\right)$$
,

where  $\mu$  is fluid viscosity and  $\Delta P/L$  is the pressure drop per unit length in the channel. **Figure 3** shows the contours of the normalized velocity field in a PSC microchannel with  $\kappa = 0.5$ .

The pressure drop and flowrate relationship for PSC microchannels was characterized by introducing a correction factor, K, to the Hagen-Poiseuille relation (see Equation (6)), in which K represents the proportion by

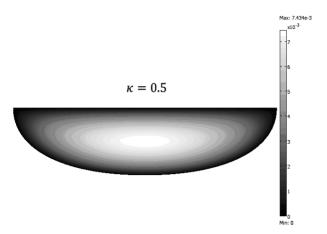


Figure 3. Normalized velocity contours for fully-developed laminar flow in a PSC microchannel for  $\kappa=0.5$ .

which the flow resistance is increased in a PSC microchannel compared to a circular duct of the same diameter. The flow correction factor increased by 6-fold as  $\kappa$  decreased from  $\kappa = 1.0$  (complete semi-circular microchannel) to  $\kappa = 0.5$  (**Figure 4(a)**).

In this range the correction factor was well fit by the power-law relation:  $K = 5.299/\kappa^{2.56}$ . For the complete semi-circular microchannel ( $\kappa = 1.0$ ), the correction factor computed from the simulations (5.279) was in agreement with that from the analytical solution (5.279) for a semi-circular microchannel (see Appendix). **Figure 4(b)** displays the correction factor plotted against the microchannel compactness factor, C. Mortensen *et al.* [12] developed a theoretical analysis showing that for microchannels of arbitrary cross-section, the hydraulic resistance varies approximately linearly with a compactness factor defined by:

$$C = \frac{P^2}{A} \tag{9}$$

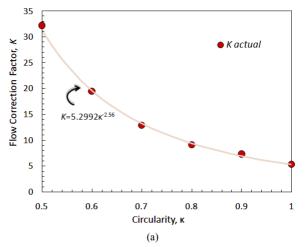
in which P and A are the microchannel perimeter and cross-sectional area, respectively. In the range of the circularity index ( $\kappa$ ) studied here, the correction factor did follow the linear relationship: K = 3.517C - 55.35 with an  $R^2$  value of 0.98.

The Hagen-Poiseuille correction factor can also be compared with predictions based on several hydraulic models for flow in arbitrary microchannels. The simplest hydraulic model would be based on using the hydraulic diameter,  $D_h = 4A/P$ , in the Hagen-Poiseuille relation. The correction factor is then given by  $D^4/D_h^4$ . **Table 1** indicates that the hydraulic diameter model significantly over-predicts the correction factor by 36% to 75% in the range of  $\kappa$  studied.

Bahrami *et al.* [13] (ref: doi:10.1016/j.ijheatmasstrans fer.2006.12.019) developed a novel approach for estimating the flow resistance of microchannels of any arbitrary cross-section. Their analysis introduces the dimen-

Table 1. Comparison of actual and predicted Hagen-Poiseuille correction factors.

К	$K_{act}^{-1}$	$K_{\scriptscriptstyle hd}^{2}$	$K_{pmi}^{3}$	$K_{se}^{-4}$
0.5	32.21	56.37	31.86	34.66
0.6	19.46	31.19	19.19	20.74
0.7	12.87	19.37	12.64	13.56
0.8	9.107	13.09	8.905	9.479
0.9	6.787	9.447	6.610	6.969
1	5.279	7.174	5.117	5.333



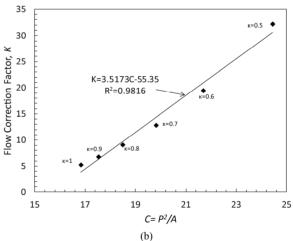


Figure 4. (a) Correction factor, K, for the Hagen-Poiseuille relation as a function of circularity index  $\kappa$ ; (b) Correction factor, K, for the Hagen-Poiseuille relation as a function of the compactness factor C.

sionless polar moment of inertia,  $I_p^*$ , computed for the microchannel geometry:

$$I_p^* = \frac{1}{A^{*2}} \int_{A^*} \left[ \left( x^* - x_c^* \right)^2 + \left( y^* - y_c^* \right)^2 \right] dA^*$$
 (10)

in which the dimensionless coordinates and cross-sectional area (denoted with asterisks) are scaled by the same dimension. (Note: Comsol automatically calculates

the polar moment of inertia and all other pertinent geometric parameters for any defined domain.) Applying their analysis to determine the Hagen-Poiseuille correction factor yields:

$$K = \frac{1}{8}\pi^3 \frac{I_p^*}{A^{*2}} \tag{11}$$

in which the dimension used to normalize for length is that used in the Hagen-Poiseuille relation itself. **Table 1** indicates that Equation (11) provides a very good estimate for the correction factor of PSC microchannels, underestimating the correction factor by only 1.1% at  $\kappa = 0.5$  to 3.1% at  $\kappa = 1.0$ .

An approximate model for the cross-sectional profile a PSC microchannel is a half-ellipsoid. While an analytical solution to the equation of fluid motion does not exist for the half-ellipsoid, Oosterbroek used a variational approach based on minimization of work, adapted from the analogous structural mechanics problem of beam torsion, to approximate the velocity profile and flow resistance for half-ellipsoid microchannels [11]. The approximate resistance, *R*, of a half-ellipsoid microchannel was determined as

$$R = \frac{32\mu L}{\pi} \frac{3a^2 + b^2}{3a^3b^3} \tag{12}$$

where a and b are the major and minor axes of the half-ellipsoid. Since b/a approximates the circularity index,  $\kappa$ , Equation (12) yields the Hagen-Poiseuille correction factor:

$$K = 4\frac{3 + \kappa^2}{3\kappa^3} \tag{13}$$

**Table 1** indicates that the correction factor based on the half-ellipsoid is also a good estimate for the correction factor for PSC microchannels, in this case over-estimating the correction factor most at small  $\kappa$ : 7.6% at  $\kappa$  = 0.5, and improving to a 1.0% over-estimate at  $\kappa$  = 1.0.

### 3.2. Wall Shear Stress Distribution

The wall shear stress associated with fully developed laminar flow in PSC microchannels would also be of interest in many applications, especially biomedical applications involving cells. The wall shear stress,  $\tau_{\scriptscriptstyle W}$ , computed directly from the dimensionless flow field is

normalized according to 
$$\tau^* = \tau_w / \left( D \frac{\Delta P}{L} \right)$$
. Figure 5

shows the variation of the normalized wall shear stress on the flat and curved surfaces of a PSC microchannel for  $\kappa=0.5$ . As would be anticipated, the maximum shear stress occurs in the middle of the flat surface for PSC microchannels.

The maximum and average values of the normalized

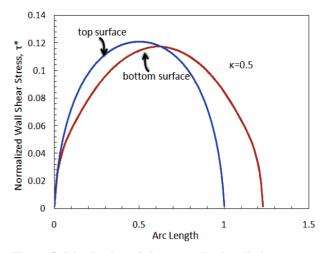


Figure 5. Distribution of the normalized wall shear stress, along the flat and curved surfaces of a PSC microchannel for  $\kappa = 0.5$ .

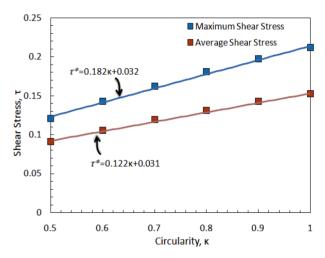


Figure 6. The linear variation in the maximum and average normalized wall shear stress with the circularity index  $\kappa$ .

wall shear stress varied approximately linearly with  $\kappa$ , as shown in **Figure 6**. The linear correlations for the maximum and average normalized wall shear stresses are:  $\tau_m^* = 0.182\kappa + 0.032$  and  $\tau_a^* = 0.122\kappa + 0.031$  (respectively). The shear stress decreased by a factor of 0.57 as  $\kappa$  decreased from unity to  $\kappa = 0.5$ .

This decrease occurs because the shear stress was normalized by the pressure drop per unit length in the microchannels. For a given flowrate, the pressure drop per unit length increases about 6-fold as  $\kappa$  decreases from  $\kappa=1.0$  to  $\kappa=0.5$  (see **Figure 4(a)**). Accordingly, for a given flowrate the shear stress would increase by approximately 3.4-fold as  $\kappa$  decreases from  $\kappa=1.0$  to  $\kappa=0.5$ . For  $\kappa=1.0$  the normalized maximum shear stress from the simulations (0.212) was in agreement with that from the analytical solution (0.212) for a semi-circular channel (Appendix).

# 4. Conclusions

1) For fully developed laminar flow in partial semi-circular (PSC) microchannels, the correction factor, K, to the Hagen-Poiseuille relationship is well fitted by the power law relation:  $K = 5.299/\kappa^{2.56}$  in the range of  $0.5 \le \kappa \le 1.0$ , where  $\kappa$  is an index of circularity relat-

ing the radius of the curved surface,  $\frac{1}{2}\kappa D$ , to that of the flat surface, D/2.

- 2) The correction factor can be predicted within 3% by a novel relationship developed for microchannels of arbitrary cross-section, which accounts for the shape of the cross-sectional profile using only the dimensionless polar moment of inertia for the profile.
  - 3) The normalized wall shear stress,  $\tau^* = \tau_w / \left( D \frac{\Delta P}{L} \right)$

increases approximately linearly with the circularity index  $\kappa$ . The maximum shear stress occurs at the center of the flat surface. The maximum (m) and average (a) normalized wall shear stresses are given  $\tau_m^* = 0.182\kappa + 0.032$  and  $\tau_a^* = 0.122\kappa + 0.031$ .

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# **Appendix**

The normalized equation of motion can be analytically solved readily for the special case of a semi-circular channel ( $\kappa = 1.0$ ). Using polar coordinates ( $r,\theta$ ) centered on the flat side of the normalized geometry, the dimensionless equation of motion is:

$$\frac{1}{r}\frac{\partial}{\partial r}\left(r\frac{\partial U}{\partial r}\right) + \frac{1}{r^2}\frac{\partial^2 U}{\partial \theta} = -1 \tag{A1}$$

with the no-slip boundary conditions:  $U(1/2,\theta) = U(r,0)$ =  $U(r,\pi) = 0$ . A separation of variables approach can be undertaken after the substitution:

$$U(r,\theta) = W(r,\theta) + \frac{1}{4}r^2(\cos 2\theta - 1)$$
 (A2)

which leads to Laplace's equation for  $W(r,\theta)$ :

$$\frac{1}{r}\frac{\partial}{\partial r}\left(r\frac{\partial W}{\partial r}\right) + \frac{1}{r^2}\frac{\partial^2 W}{\partial \theta} = 0 \tag{A3}$$

with the same no-slip conditions as for U with the exception  $W\left(\frac{1}{2},\theta\right) = -\frac{1}{16}(\cos 2\theta - 1)$ .

A straight-forward separation of variables solution to Equation (A3) can be performed resulting in a series solution for  $W(r,\theta)$ . Substituting that solution into Equation (A2) results in the normalized velocity profile for a semi-circular channel:

$$U(r,\theta) = \frac{1}{4}r^{2}(\cos 2\theta - 1)$$

$$-\frac{1}{2\pi}\sum_{n=1}^{\infty} 2^{2n} \frac{r^{2n-1}\sin[(2n-1)\theta]}{(2n-1)(2n+1)(2n-3)}$$
(A4)

The integrals and derivatives leading to the Hagen-Poiseuille correction factor and normalized wall shear stress are straightforward and hence are not provided here.